

**Search Notes**

Application/Control No.

10/812,986

Examiner

Stephen W. Smoot

Applicant(s)/Patent under  
Reexamination

JUNG, YUN-HO

Art Unit

2813

**SEARCHED**

Class	Subclass	Date	Examiner
219	121.6	2/18/2005	SWS
250	492.22	2/18/2005	SWS
257	75	2/18/2005	SWS
257	E21.134	2/18/2005	SWS
430	5	2/18/2005	SWS
438	487	2/18/2005	SWS
438	943	2/18/2005	SWS
438	946	2/18/2005	SWS

*S.W.S.***INTERFERENCE SEARCHED**

Class	Subclass	Date	Examiner

**SEARCH NOTES  
(INCLUDING SEARCH STRATEGY)**

	DATE	EXMR
Key Words: Sequential Lateral Solidification - SLS, Crystallization, Grain Growth;	2/18/2005	<i>S.W.S.</i> SWS
Amorphous Silicon; Polysilicon; Mask; Laser.	2/18/2005	<i>S.W.S.</i> SWS
Search Tools - EAST (attached): USPAT; US PG PUBS; Derwent; EPO; JPO; IBM TDB	2/18/2005	<i>S.W.S.</i> SWS